MPI T53500 300 mm Automated Probe Systems

Cost-Effective System for RF, mmW and Product Engineering

FEATURES / BENEFITS

Designed for Variety of On-Wafer Applications

- DC-IV / DC-CV / Pulsed-IV applications
- RF, mmW, load-pull applications & 4-port setup
- IC Design Validation, Failure Analysis in wide temperature range from 20 to 300 °C

WaferWallet® Option

- Designed with five individual trays for manual, ergonomic loading of 150, 200, or 300 mm "modeling" wafers
- Fully-automated tests with up to five identical wafers at multiple temperatures
- Unique capability to load/unload wafers at any temperature

Extended Flexibility

- Using MicroPositioners and probe cards simultaneously
- Programmable microscope movements for more automation and ease of use
- The shortest cable interface to IC tester
- Minimize the platen-to-chuck distance for mmW & probing with active probes
- · Supports film-frame probing
- Upgradable with IceFreeEnvironment™

Ergonomic Design and Footprint

- Easy wafer or single DUT loading from the front
- Integrated active vibration isolation
- Completely integrated prober control for faster, safer and convenient system and test operation
- The Safety Test Management (STM™) with automated dew point control
- Reduced footprint due to smart chiller space arrangement
- Instrument shelf option for shorter cables and higher measurement dynamic



STAGE SPECIFICATIONS

Chuck XY Stage (Programmable)

on months of the go (1 1 o gramma to)	
Travel range	310 mm x 530 mm (12.2 x 20.87 in)
Resolution	0.5 μm
Accuracy	< 2.0 μm (0.08 mils)
XY stage drive	Closed-loop high precision stepper motors
Speed	5-Speed XY chuck stage speed movement
Max. movement speed	50 mm / sec

Chuck Z Stage (Programmable)

chuck 2 Stage (Frogrammable)	
Travel range	30 mm (1.18 in)
Resolution	0.2 μm
Accuracy	< 2 μm
Repeatability	<1 µm
Z stage drive	Closed-loop high precision stepper motor
Guider	Precision ball bearings

STAGE SPECIFICATIONS

Chuck Theta Stage (Programmable)

Travel range	± 5.0°
Resolution	0.0001° (0.24 μm @ 300 mm edge)
Accuracy	$<$ 2.0 μm (measured at the edge of the 300 mm chuck)
Repeatabilty	< 1.0 µm
Theta stage drive	High resolution stepper motor with linear encoder feedback system

MANUAL WAFER LOADING

Loading or unloading of 150, 200 or 300 mm wafers or substrates is straight forward and intuitive. Special designed chucks allowing easy single ICs or wafer fragments loading in the front. Furthermore MPI SmartVacuum™ technology allows automated wafer size or single Die recognition and protects the wafer in case of power interruptions or inexperience operators from releasing the vacuum inside the IceFreeEnvironment™.

No roll-out stage allows for a simple method of automation for RF calibration and probe card cleaning. Easy access to the AUX chucks for handling of calibration substrates, cleaning or contact check pads.







AUTOMATED WAFER LOADING OPTIONS

WaferWallet®



Wafer loading trays	5
Supported wafer sizes	150, 200, or 300 mm
Individual notch marks	0, 90, 180 & 270 deg for all wafer sizes
Hot and cold wafer swapping	Yes, local environmental chamber
Wafer pre-aligner	For 150, 200 and 300 mm, option
Wafer ID-Reader	Option for top or bottom ID reading Revolutionary integrated RGB illumination Fully automatic exposure control Code shift compensation OCR, Barcode, DataMatrix and QR code
Signal light tower	Four color, LED steady/flashing tower lights

WaferWallet®MAX

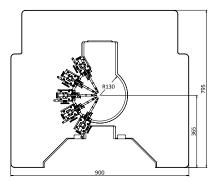


Number of cassettes Cassette type Supported wafer sizes Pre-aligner and cassette scanner	1 Semi Standard, opened 150, 200 or 300 mm Included
Wafer ID-Reader	Option for top or bottom ID reading Revolutionary integrated RGB illumination Fully automatic exposure control Code shift compensation OCR, Barcode, DataMatrix and QR code
Signal light tower	Four color, LED steady / flashing tower lights

PROBE PLATEN

Specifications

Material	Nickel plated steel
Chuck top to platen top	Min. 28 mm
Platen cooling	Fully integrated CDA cooling, by using the chiller CDA
Configuration	Probe card holder 4.5 x 11" and/or MicroPositioners
Max. No. of MicroPositioners	10x DC MicroPositioners or 4x DC + 4x HF MicroPositioner Setup
RF MicroPositioner mounting	Magnetic with guided rail
DC MicroPositioner mounting	Magnetic





Large Probe Platen supporting up to 10x DC or 4x DC + 4x RF MicroPositioners or standard 4.5" probe card holder

MICROSCOPE MOVEMENT

XYZ Programmable

•	
XY - Travel range*	50 x 50 mm / 300 x 300 mm
Resolution	1 μm (0.04 mils)
Repeatability	≤ 2 µm (0.08 mils)
Accuracy	≤ 5 µm (0.2 mils)
Z - Travel range	140 mm
Resolution	0.05 μm (0.002 mils)
Repeatability	≤ 2 µm (0.08 mils)
Accuracy	≤4 µm (0.16 mils)

^{*}In case of ShielDEnvironment $^{\text{TM}}$ X x Y: 25 mm x 25 mm



KEY FEATURES

INTEGRATED CONTROLS

The thermal chuck can be operated by using the fully integrated touchscreen display, placed at convenient location in front of the operator for fast operation and immediate feedback.

The intelligent hardware control panel is completely integrated into the probe system and is designed to provide faster, safer and convenient system control and test operation.

The Keyboard and mouse are strategically located to control the software and it can also control the Windows® based instrumentation.

USB connection to the systems controller is located right in front for convenient data exchange.







OPTIONAL FEATURES

IceFreeEnvironment™

MPI IceFreeEnvironment™ provides unique capability to perform measurements with probe cards and MicroPositioners simultaneously, especially at negative temperatures down to -60°C.

Internal node probing with active/passive high impedance probes is very convenient.

The optimized design with minimal tip drop for highest dynamic range and gamma of mmWave and Load Pull measurements make the system an ideal choice for RF/mmW applications on 300 mm wafers.





Probe Hover Control™

MPI Probe Hover Control PHC™ allows easy manual control of probe contact and separation to wafer. Separation distance can accurately control with micrometer feedback for probe to wafer/pad positioning. Ease of use guarantees the safest operation by minimizing error during critical setup and probe change operations.



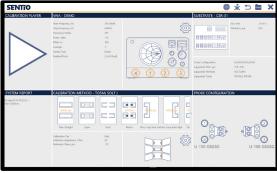
SOFTWARE SOLUTION

MPI automated engineering probe systems are controlled by a unique and revolutionary, multi-touch operation SENTIO® Software Suite – simple and intuitive operation saves significant training time, the Scroll, Zoom, and Move commands mimic modern smart mobile devices and allows everyone to become an expert in just minutes. Switching between the active application and the rest of the APPs is just a matter of a simple finger sweep.

By implementing intuitive multi-touch operation, QAlibria® provides crisp and clear guidance to the RF calibration process, minimizes configuration mistakes and helps to reach accurate calibration results in fastest time. QAlibria® offers industry standard and advanced calibration methods.

QAlibria® includes TOSM (SOLT), TMR, TMRR methods, and 4-port calibration capability additionally to the integration of NIST StatistiCal calibration packages providing easy access to the NIST multiline TRL metrology-level calibration and uncertain analysis.





NON-THERMAL CHUCKS

Wafer Chuck	Standard	Triaxial
Connectivity	Coax BNC (f)	Kelvin Triax (f)
Diameter	310 mm with 2 integrated AUX area	s
Material	Nickel plated aluminum (flat with 0	.5 mm holes)
Chuck surface	Planar with 0.5 mm diameter holes	in centric sections
Vacuum holes sections (diameter)	4, 24, 48, 72, 96, 120, 144, 168, 192,	216, 240, 264, 288 mm
SmartVacuum™ distribution	In front for single DUT 5x5 mm (4 ho In center for 150, 200, 300 mm (6, 8	, ,
Surface planarity	≤± 5 μm**	
Rigidity	< 15 μm / 10 N @edge	

 $^{{}^{\}star} Single\ DUT\ testing\ requires\ higher\ vacuum\ conditions\ dependent\ upon\ testing\ application.$

Triaxial RF Wafer Chuck

Connectivity	Kelvin Triax (f)
Diameter	310 mm with 2 integrated AUX chucks
Material	Nickel plated aluminum (flat with 0.5 mm holes)
Chuck surface	Planar with 0.5 mm diameter holes in centric sections
Vacuum holes sections (diameter)	4, 24, 48, 72, 96, 120, 144, 168, 192, 216, 240, 264, 288 mm
SmartVacuum™ distribution	In front for single DUT 5x5 mm (4 holes) and 75 mm (3 in) In center for 150, 200, 300 mm (6, 8, 12 in)
Surface planarity	≤± 5 μm**
Rigidity	< 15 µm / 10 N @edge

^{*}Single DUT testing requires higher vacuum conditions dependent upon testing application.

Auxiliary Chuck

Quantity	2 AUX chucks
Position	Integrated to front side of main chuck
Substrate size (W x L)	Max. 25 x 25 mm (1 x 1 in)
Material	Ceramic, RF absorbing material for accurate calibration
Surface planarity	≤± 5 μm
Vacuum control	Controlled independently, separate from chucks

Electrical Specification (Coax)

Operation voltage	In accordance with EC 61010, certificates for higher voltages available upon request
Maximum voltage between chuck top and GND	500 V DC
Isolation	> 2 GΩ

Electrical Specification (Triax)

Chuck Isolation	At 10 V
Force-to-Guard	> 5 T Ohm
Guard-to-Shield	> 1 T Ohm
Force-to-Shield	> 5 T Ohm

^{**}By using SENTIO® topography

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THERMAL CHUCKS

Specifications of MPI ERS AirCool® PRIME Technology

Chuck type RF RF Ultra low noise Ultra low noise Connectivity Kelvin Triax (f) Cooling air / Resistance heater Cooling air / Resistance heater Resistance heater Resistance heater Resistance heater Air (user supplied)		Ambient to 200/300 °C	20 °C to 200/300 °C	Ambient to 200/300 °C	20 °C to 200/300 °C
Temperature control method Resistance heater Air (user supplied) Air (use	Chuck type	RF	RF	Ultra low noise	Ultra low noise
method Resistance heater Resistance heater Resistance heater Resistance heater Resistance heater Resistance heater Coolant Air (user supplied) Air (user supplied) <td>Connectivity</td> <td>Kelvin Triax (f)</td> <td>Kelvin Triax (f)</td> <td>Kelvin Triax (f)</td> <td>Kelvin Triax (f)</td>	Connectivity	Kelvin Triax (f)	Kelvin Triax (f)	Kelvin Triax (f)	Kelvin Triax (f)
Smallest temperature selection step 0.1 °C 0.01 °C 0.00 °C ±0.08 °C <t< td=""><td>•</td><td></td><td>0 ,</td><td>•</td><td>•</td></t<>	•		0 ,	•	•
selection step 0.1 °C 0.01 °C ±0.08 °C	Coolant	Air (user supplied)	Air (user supplied)	Air (user supplied)	Air (user supplied)
Supply resolution Supply resolution Supply resolution Yes		0.1 °C	0.1 °C	0.1 °C	0.1 °C
display operation Yes	•	0.01 °C	0.01 °C	0.01 °C	0.01 °C
Temperature accuracy t±0.1 °C 0.1 °C 0.2 °C 0.3 °C at ≤ 200 °C 0.2 °C 2.4 ⊆ 200 °		Yes	Yes	Yes	Yes
Control method Low noise DC/PID P100 DA Low noise DC/PID	Temperature stability	±0.08 °C	±0.08 °C	±0.08 °C	±0.08 °C
Chuck pinhole surface plating: 200°C / 300°C Nickel / Gold 201 (300) Nickel / Gold Nickel / G	Temperature accuracy	±0.1 °C	0.1 °C	0.1 °C	0.1 °C
Plating: 200°C / 300°C SmartVacuum™ In front for single DUT 5x5 mm (4 holes) and 75 mm (3 in) distribution In center for 150, 200, 300 mm (6, 8, 12 in)	Control method	Low noise DC/PID	Low noise DC/PID	Low noise DC/PID	Low noise DC/PID
distribution In center for 150, 200, 300 mm (6, 8, 12 in) Temperature sensor Pt100 1/3DIN, 4-line wired Pt100 1/3DIN,		Nickel / Gold	Nickel / Gold	Nickel / Gold	Nickel / Gold
4-line wired 4-l		In fro	O	,	n (3 in)
Surface flatness and base parallelism <±12 μm	Temperature sensor				The state of the s
base parallelism < ±12 μm ±12 μm <th< td=""><td>Temperature uniformity</td><td></td><td></td><td></td><td></td></th<>	Temperature uniformity				
Force-to-GND 600 V DC 400 V DC		<±12 μm	<±12 μm	<±12 μm	<±12 μm
Force-to-Guard 100 V DC 100 V DC 600 V DC 600 V DC Guard-to-GND 400 V DC 400 V DC 400 V DC 400 V DC Heating rates* 35 to 200 °C < 16 min 35 to 300 °C < 29 min 35 to 300 °C < 30 min 35 to 300 °C < 33 min 20 to 300 °C < 31 min 300 to 35 °C < 24 min 300 to 35 °C < 27 min 300 to 20 °C < 42 min 300 to 35 °C < 27 min 300 to 20 °C < 42 min 300 to 35 °C < 31 min 300 to 35 °C < 31 min 300 to 35 °C < 31 min 300 to 35 °C < 30 min 20 to 30 °C < 30 min 20 to 30 °C < 31 min 300 to 35 °C < 30 fA at 25 °C < 50 fA at 300 °C < 30 fA at 200 °C < 30 fA at 200 °C < 50 fA at 300 °C < 50 fA	Max. Voltage between				
Guard-to-GND 400 V DC Heating rates* 35 to 200 °C < 16 min 35 to 300 °C < 29 min 35 to 300 °C < 30 min 35 to 300 °C < 33 min 20 to 300 °C < 34 min 20 to 35 °C < 24 min 300 to 35 °C < 27 min 300 to 35 °C < 27 min 300 to 20 °C < 42 min 300 to 35 °C < 27 min 300 to 20 °C < 42 min 300 to 35 °C < 31 min 300 to 20 °C < 50 min 300 to 20 °C < 50 min 300 to 20 °C < 50 fA at 25 °C < 30 fA at 200 °C < 30 fA at 200 °C < 50 fA at 300 °C < 15 fA at 25 °C < 30 fA at 200 °C < 50 fA at 300 °C < 50 fA at 300 °C < 50 fA at 300 °C N/A	Force-to-GND	600 V DC	600 V DC	600 V DC	600 V DC
Heating rates* 35 to 200 °C < 16 min 35 to 300 °C < 29 min 35 to 300 °C < 29 min 35 to 300 °C < 30 min 35 to 300 °C < 33 min 20 to 300 °C < 33 min 20 to 35 °C < 24 min 300 to 35 °C < 24 min 300 to 35 °C < 27 min 300 to 20 °C < 42 min 300 to 35 °C < 27 min 300 to 35 °C < 27 min 300 to 35 °C < 31 min 300 to 20 °C < 42 min 300 to 35 °C < 31 min 300 to 35 °C < 30 fA at 300 °C < 30 fA at 300 °C 300 to 35 °C < 31 min 300 to 30 °C 300 to 35 °C < 31 min 300 to 30 °C 300 to 35 °C < 31 min 300 to 30 °C 300 to 30 °C < 30 fA at 300 °C 300 fA at 300 °C <t< td=""><td>Force-to-Guard</td><td>100 V DC</td><td>100 V DC</td><td>600 V DC</td><td>600 V DC</td></t<>	Force-to-Guard	100 V DC	100 V DC	600 V DC	600 V DC
35 to 300 °C < 29 min 20 to 300 °C < 30 min 35 to 300 °C < 33 min 20 to 300 °C < 34 min 200 to 35 °C < 24 min 300 to 35 °C < 27 min 300 to 20 °C < 35 min 300 to 35 °C < 27 min 300 to 20 °C < 42 min 300 to 35 °C < 31 min 300 to 20 °C < 50 min 200 °C < 30 fA at 200 °C < 30 fA at 200 °C < 30 fA at 200 °C < 50 fA at 300	Guard-to-GND	400 V DC	400 V DC	400 V DC	400 V DC
300 to 35 °C < 27 min 300 to 20 °C < 42 min 300 to 35 °C < 31 min 300 to 20 °C < 50 min Leakage @ 10 V	Heating rates*				
N/A N/A < 30 fA at 200 °C < 30 fA at 200 °C < 50 fA at 300 °C N/A N/A N/A Capacitance Force-to-Guard < 1600 pF	Cooling rates*				
$ \begin{array}{c ccccccccccccccccccccccccccccccccccc$	Leakage @ 10 V	N/A	N/A	< 30 fA at 200 °C	< 30 fA at 200 °C
Force-to-Guard < 1600 pF < 1600 pF < 600 pF < 600 pF	Electrical isolation	> 1 T Ω at 200 °C	> 1 T Ω at 200 °C	N/A	N/A
тер тер	Capacitance				
Guard-to-Shield < 2000 pF < 2000 pF < 2000 pF < 2000 pF	Force-to-Guard	< 1600 pF	< 1600 pF	< 600 pF	< 600 pF
	Guard-to-Shield	< 2000 pF	< 2000 pF	< 2000 pF	< 2000 pF

^{*}Typical data for all chucks based on FPS requirements.

THERMAL CHUCKS DIMENSIONS

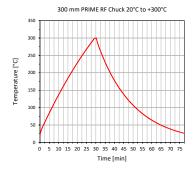
System Controller / Chiller Dimensions and Power / Air Consumption

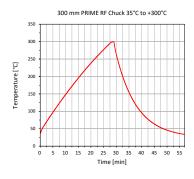
System type	W x D x H (mm)	Weight (kg)	Power cons. (VA)	max. Air flow* (l/min)	CDA dew Point
Ambient	300 x 360 x 135	12	1200	400	≤ 0 °C
20 °C to 200 / 300 °C	300 x 360 x 135	12	1200	400	≤ -30 °C
Electrical primary connection		10	00 to 240 VAC aι	ıto switch	
Electrical frequency			50 Hz / 60	Hz	
Compressed air supply		(6.0 bar (0.8 MPa	, 87 psi)	

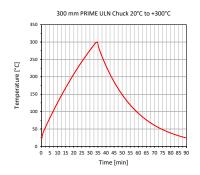


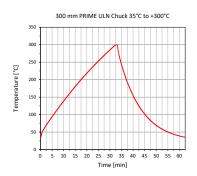
ERS and MPI's joint product AirCool® PRIME Chuck won "Electronics Industry Awards 2018" in the category, "Test, Measurement and Inspection Product of the year".

TYPICAL TRANSITION TIME









SYSTEM CONTROLLER SPECIFICATIONS

CPU	Intel® Core™ i7-7700,3.6 GHz, 8M Cache, 14nm, 65W TDP, LGA1151 (4C/8T)
RAM	DDR4 2400 MHz 16 GB x 1
64 bit operating system	Windows 10 Professional (English)
Power	460 W
Storage	SSD 500 GB
LAN	One internal and one external TCP/IP ports
USB Ports	Internal (on PC) x3, external x1
GPIB interface	Optional

SUPPORTED SOFTWARE PLATFORMS

Drivers	WaferPro / IC-CAP & EasyEXPERT from Keysight, BSIMPro & NoisePro from ProPlus, ACS from Keithley
Emulation mode	Available for various prober control software*

^{*} Please contact your local support for more details.

FACILITY REQUIREMENTS

General Probe System

Power	100-240 V AC nominal ; 50/60 Hz
Vacuum	-0.9 bar
Compressed air	6.0 bar

REGULATORY COMPLIANCE

3rd party, TÜV tested according to

• IEC 61010-1: 2010 + Am1:2016; EN 61010-1: 2010; IEC/EN 61010-2-010: 2014; IEC/EN 61010-2-081: 2015; EN ISO 12100: 2010; UL 61010-1: 2012/R: 2016-04; UL 61010-2-010: 2015; CAN/CSA-C22.2 No. 61010-1: 2012/U2: 2016-04; CAN/CSA-C22.2 No. 61010-2-010:2015

and certified for CE and US/Canada (NRTL), SEMI S2 and S8.

Copies of certificates are available on request

WARRANTY

- Warranty*: 12 months
- Extended service contract: contact MPI Corporation for more information

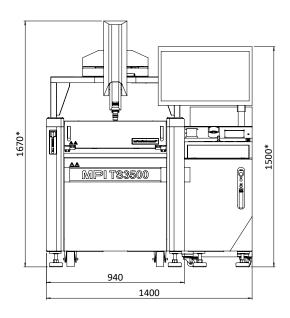
^{*}See MPI Corporation's Terms and Conditions of Sale for more details.

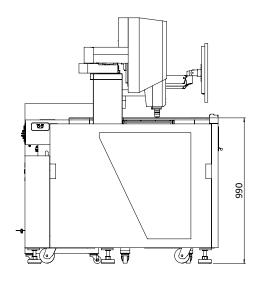
PHYSICAL DIMENSIONS

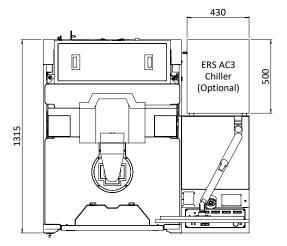
TS3500

System dimensions (W x D x H)	1400 x 1315 x 1670 mm (55.1 x 51.8 x 65.7 in)
Weight	850 kg

^{*}Can vary depends on monitor/chiller position.





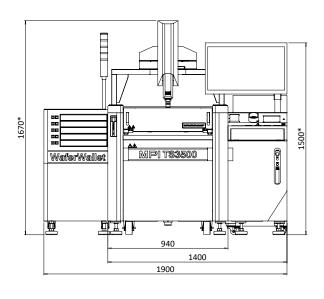


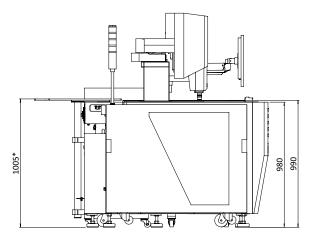
WaferWallet®

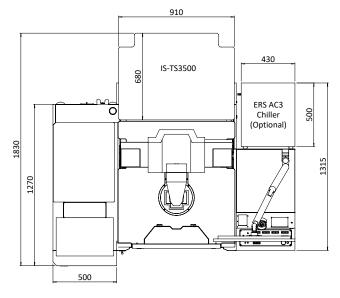
System dimensions (W x D x H)	500 x 1270 x 980 mm (19.7 x 50.0 x 38.6 in)
Weight	180 kg

^{*}Can vary depends on monitor/chiller position.

TS3500 with WaferWallet®





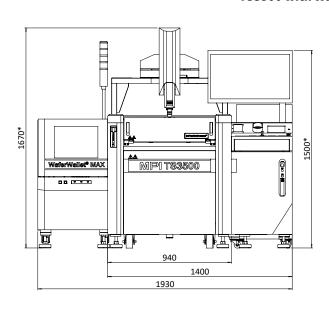


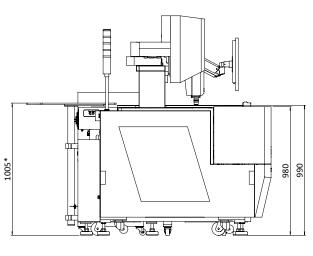
WaferWallet®MAX

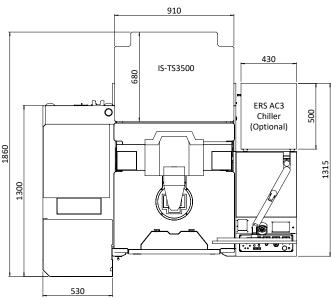
System dimensions (W x D x H)	530 x 1300 x 980 mm (20.9 x 51.2 x 38.6 in)
Weight	200 kg

^{*}Can vary depends on monitor/chiller position.

TS3500 with WaferWallet®MAX







Asia region: ast-asia@mpi-corporation.com
EMEA region: ast-europe@mpi-corporation.com
America region: ast-americas@mpi-corporation.com

MPI global presence: for your local support, please find the right contact here: www.mpi-corporation.com/ast/support/local-support-worldwide

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